

**INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT**

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<b>Application Number</b>	10/735,769
<b>Confirmation Number</b>	3973
<b>Filing Date</b>	December 16, 2003
<b>First Named Inventor</b>	Koichi KAWAMURA
<b>Art Unit</b>	1756
<b>Examiner Name</b>	NOT YET ASSIGNED
<b>Attorney Docket Number</b>	Q79007

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U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.†	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		Number	Kind Code* (if known)		
		US			
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NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (In CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation <sup>6</sup>
YSD		YOSHINOBU TSUJII ET AL. : "Fabrication of patterned high-density polymer graft surfaces. II. Amplification of EB-patterned initiator monolayer by surface-initiated atom transfer radical polymerization", POLYMER, ELSEVIER SCIENCE PUBLISHERS B.V, GB, vol. 43, no. 13, June 2002, pages 3837-3841, XP004349557	
YSD		RAHUL R. SHAH, ET AL., "Using atom transfer radical polymerization to amplify monolayers of initiators patterned by microcontact printing into polymer brushes for pattern transfer", MACROMOLECULES, vol. 33, no. 2, August 1, 2000, pages 597-605, XP002273494	
YSD		KRZYSZTOF MATYJASZEWSKI, et al., "Atom transfer radical polymerization", CHEMICAL REVIEWS, AMERICAN CHEMICAL SOCIETY. EASTON, US, vol. 101, no. 9, December 9, 2001, pages 2921-2990, XP002212148	
YSD		YOUNAN XIA, ET AL., "Soft Lithography", ANGEWANDTE CHEMIE. INTERNATIONAL EDITION, VERLAG CHEMIE. WEINHEIM, DE, vol. 37, 1998, pages 550-575, XP002149045	

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<sup>1</sup> Applicant's unique citation designation number (optional). <sup>2</sup> See Kind Codes of USPTO Patent Documents at [www.uspto.gov](http://www.uspto.gov), MPEP 901.04 or in the comment box of this document. <sup>3</sup> Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). <sup>4</sup> For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. <sup>5</sup> Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. <sup>6</sup> Applicant is to indicate here if English language Translation is attached.